Growth of colorless silicon carbide crystals (US5718760)

IPN Home Sea	arch Sho	II PP Fe	ntellectu edback	al Property Network
	US5718760: Growth of colorless silicon carbide crystals			
		<u> </u>		
Inventor(s):	Carter; Calvin H. , Cary, NC Tsvetkov; Valeri F. , Durham, NC Glass; Robert C. , Chapel Hill, NC			
Applicant(s):	Cree Research, Inc., Durham, NC			
Issued/Filed Dates:	Feb. 17, 1998 / Feb. 5, 1996			
Application Number:	US1996000596526			
IPC Class:	C30B 029/36;			
Class:	117/084; <u>117/089;</u> <u>117/093;</u> <u>117/102;</u>			
Field of Search:	117/84,89,93,95,102,937 <u>423/446</u> 437/22,100			
Abstract: Attorney, Agent, or	Large single crystals of silicon carbide are grown in a furnace sublimation system. The crystals are grown with compensating levels of p-type and n-type dopants (i.e., roughly equal to levels of the two dopants) in order to produce a crystal that is essentially colorless. The crystal may be cut and fashioned into synthetic gemstones having extraordinary toughness and hardness, and a brilliance meeting or exceeding that of diamond. Summa. Patent Attorney: Philip:			
Firm: Primary/Assistant Examiners:	Garrett; Felisa;			
U.S. References:	(No patents re	ference this o	ne)	
	Patent	Inventor	Issued	Title
	US4966860	Suzuki et al.	10 /1990	Process for producing a SiC semiconductor device
	<u>US5030580</u>	Furukawa et al.	7 /1991	Method for producing a silicon carbide semiconductor device
	<u>US5433167</u>	Furukawa et al.	7 /1995	Method of producing silicon-carbide single crystals by sublimation recrystallization process using a seed crystal

none

First Claim:

Show all 11 claims

That which is claimed:

1. A method of producing a colorless single crystal of silicon carbide comprising growing a single crystal of silicon carbide by a sublimation technique while introducing compensated levels of ptype and n-type dopants into a crystal lattice structure.

Foreign References:

(No patents reference this one)

Other References:

- Introduction to Ceramics, W. D. Kingery et al., Second Edition, John Wiley & Sons, pp. 676-679.
- Optical and Electronic Properties of SiC, W. H. Choyke, The Physics and Chemistry of Carbides, Nitrides and Borides, Manchester, England, Sep. 1989, pp. 1-25.

